

INDEX OF AUTHORS

<u>AUTHOR</u>	<u>SESSION</u>	<u>PAGE</u>	<u>AUTHOR</u>	<u>SESSION</u>	<u>PAGE</u>
Abdel-Malek, H.L.	B2.3	79	Clifton, B.J.	C6.4, C6.5	430, 433
Abe, H.	Panel	479	Cockrill, J.	A5.1	300
Adelsek, B.	B1.1	21	Cohen, L.D.	B1.3	27
Agarwal, K.K.	A6.3	393	Cohen, M.	D1.1	33
Aiga, M.	D5.7	380	Coleman, P.D.	C6.1	424
Akaike, M.	B3.4	162	Collins, J.H.	D6.1	440
Akasaka, S.	A2.7	67	Cotton, J.M.	A6.5	399
Allen, C.	A6.1	386	Crescenzi, E.J., Jr.	A3.1	129
Alley, G.D.	C6.4	430	Cripps, S.C.	A5.1	300
Allison, R.C.	D1.4	44	Cuccia, C.L.	A2.6	463
Andersen, J.B.	D3.5	198	Curtice, W.R.	A2.8	70
Ando, M.	A5.5	312			
Arndt, G.D.	C4.5	273	Dalby, A.	A4.6	223
Araki, K.	D3.6	201	D'Ambrosio, A.	C2.5	105
Asakura, T.	D2.5	119	de Bruyl, J.	A6.1	386
Ashida, H.	D4.1	276	Delconte, T.R.	A6.5	399
Azarbar, B.	D3.4	195	de Santis	A3.2	132
			Duder, T.	A3.3	135
Baba, K.	B3.6	168			
Babbitt, R.W.	C2.1	94	Eastman, L.F.	A3.8, D5.5	150, 375
Ban, K.	B3.6	168	Eisenhart, R.L.	A5.7, D1.4	44, 318
Bandler, J.W.	B2.3	79	El-Behery, I.N.	B5.8	341
Barabino, Giovanni	B6.8	422	Emswiler, W.	B5.1	321
Barabino, Guilio	B6.8	422	Endo, H.	B3.6	168
Beal, J.C.	C4.4	270	Engen, G.F.	C3.0, C3.3, C3.4	174, 182, 184
Begemann, G.	B1.2	24	English, D.L.	D5.3	369
Bell, A.B.	B4.6	251	Erickson, N.R.	C6.5, C6.7	433, 438
Bessho, M.	B4.1	236	Ernst, R.L.	A3.7	147
Bianco, B.	B6.8	422	Estabrook, P.	A3.1	129
Biberman, L.	Panel	484			
Bock, G.F.	A5.6	315	Feldmann, M.	D6.7	456
Bondyopadhyay, P.K.	B5.6	336	Felsen, L.B.	D2.2	112
Bowers, R.	A1.3	20	Fetterman, H.R.	C6.4, C6.5	430, 433
Boyko, L.L.	C5.8	360	Fitzgerald, W.D.	C6.5	433
Bozler, C.O.	C6.4	430	Fitzpatrick, J.K.	C3.6	475
Brown, W.C.	C5.4	349	Frøysa, P.	C3.5	186
			Fugono, N.	B3.7, B4.7	171, 254
Camisa, R.L.	A3.7	147	Fujiki, N.	B3.6	168
Cardiasmenas, A.G.	A6.5	399	Fukada, S.	A2.7	67
Chang, C.	D2.6	121	Fukazawa, A.	B4.1	236
Chang, D.C.	B6.4	411	Fukui, K.	C5.7	357
Chang, K.K.	B6.7	419			
Chao, C.L.	B2.1	73	Gale, D.J.	C4.4	270
Chen, P.T.	A5.4	309	Gaspari, R.A.	A2.3	58
Childs, W.	A2.5	64	Gewartowski, J.W.	D4.2	279
Cho, A.Y.	A6.4	396	Goel, J.	A3.7	147
Chow, Y.L.	B5.8	341	Goldie, H.	C5.6	354
Chudobiak, W.J.	D4.6	291	Goodwin, F.E.	B4.4	245
Claxton, D.	Panel	483	Grayzel, A.I.	B5.1, B5.4	321, 329

INDEX OF AUTHORS

<u>AUTHOR</u>	<u>SESSION</u>	<u>PAGE</u>	<u>AUTHOR</u>	<u>SESSION</u>	<u>PAGE</u>
Greiling, P.T.	D1.4, Panel	44, 483	Kanmuri, N.	B3.4, A5.5	162, 312
Griffin, E.L.	D1.5	47	Kaswen, M.	Panel	484
Haddad, G.I.	B2.5, D5.4	85, 372	Katayama, S.	D5.2	366
Haga, I.	A2.7, A5.5	67, 312	Keyes, L.A.	B4.6	251
Hagihara, E.	B3.4	162	Khan, P.J.	B6.7	419
Hammerstad, E.	C3.5	186	Khandelwal, D.D.	C5.3	346
Harris, D.J.	C6.3	427	Kim, C.S.	D2.8	127
Harrison, R.G.	B4.8	257	Kim, K.J.	C6.1	424
Hartmann, C.S.	D6.5	453	Kinoshita, Y.	D6.6	472
Hasumi, H.	D5.2	366	Kiyoto, M.	B3.6	168
Hata, M.	B4.1	236	Knighten, J.L.	B6.6	416
Hayakawa, T.	B3.2	156	Knoechel, R.	A6.2	390
Hayasaka, T.	D4.7	294	Kobayashi, Y.	A4.9	233
Hayashi, R.	B3.7	171	Kojima, H.	D6.6	472
Hebert, A.S.	B1.4, B2.2	30, 76	Komiyama, N.	A2.4	61
Henaff, J.	D6.7, Panel	456, 481	Krowne, C.M.	A3.1	129
Hersman, M.S.	B4.4	245	Krumm, C.F.	D5.8, Panel	383, 483
Hessel, A.	B5.6	336	Kruse, P.	Panel	484
Higgins, J.A.	A3.4	138	Kudsia, C.M.	A4.5	220
Higuchi, M.	B4.1	236	Kuhnle, J.	C3.5	186
Hines, M.	A6.6	402	Kumagai, N.	D6.4	450
Hirayama, M.	C6.6	435	Kumar, S.	D4.6	291
Ho, P.T.	A3.5	142	Kuo, Y.L.	A6.3	393
Hoefler, W.J.R.	B6.2	471	Kurebayashi, H.	C2.2	97
Hoer, C.A.	C3.1, C3.4	176, 184	Kurematsu, H.	D4.1	276
Hofmann, H.	B1.1	21	Kuwahara, T.	B5.7	338
Hoft, D.J.	B4.2	239	Kvarna, Y.	Panel	477
Horikiri, K.	D5.7	380	LaTourrette, P.M.	A4.3	214
Hornbuckle, H.P.	D4.5, Panel	288, 483	Lean, M.H.	D3.1	466
Hsu, J.P.	B6.3	408	Leap, J.W.	C6.1	424
Hutchinson, D.P.	C6.2	469	Lederer, E.H.	C5.8	360
Imai, M.	D2.5	119	Lee, K.W.	C6.3	427
Inada, K.	B3.2	156	Lee, Y.S.	D1.2	37
Irie, T.	A1.4	460	Leopold, L.	C4.5	273
Ishibashi, T.	C6.6	435	Levine, N.	Panel	484
Ishihara, F.	B3.1	153	Leviton, A.C.	C5.1	468
Ishikawa, Y.	A4.8	230	Levy, R.	A4.2	211
Itoh, T.	B1.4, B2.2, D2.6	30, 76, 121	Li, C.T.	A5.4	309
Ivanek, F.	Panel	476	Lindauer, G.A.	C2.3	100
Iwabe, A.	B3.6	168	Linke, R.A.	A6.4	396
Iwasaki, R.S.	B4.5	248	Lombardo, P.	A6.1	386
Jeng, G.	D3.1	466	Luypaert, P.J.	B6.5	413
Johnson, R.E.	D2.7	124	Ma, C.H.	C6.2	469
Kajiware, Y.	D5.7	380	Macksey, T.I.	D4.3	282
Kallianteris, S.	A4.5	220	Maekawa, E.	B5.3	326
Kaneko, K.	A5.5	312	Mahle, C.E.	A2.5	64
			Mains, R.K.	B2.5	85

INDEX OF AUTHORS

<u>AUTHOR</u>	<u>SESSION</u>	<u>PAGE</u>	<u>AUTHOR</u>	<u>SESSION</u>	<u>PAGE</u>
Makino, S.	B4.1	236	Pan, J.J.	A5.3	306
Malk, E.G.	C6.1	424	Parekh, J.O.	D6.3	447
Marazzi, E.	B2.6	88	Parker, C.O.	C6.5	433
Marcatili, E.A.J.	D2.1	111	Parker, T.E.	Panel	482
Masnari, M.A.	B2.5	85	Parodi, M.	B6.8	422
Mastroianni, R.G.	C5.1	468	Payne, J.	Panel	484
Masuda, Y.	B5.7	338	Peng, S.T.	B6.3	408
Matsumoto, H.	A4.8	230	Peterson, D.J.	D4.8	297
Mazumder, S.	C4.2	263	Phipps, C.	A1.1	459
McCleer, P.J.	D5.4	372	Piotrowski, W.S.	C2.4	103
McGovern, P.A.	D3.2	189	Plant, T.K.	D2.7	124
McMullen, J.G.	C5.3	346	Plourde, J.K.	Panel	480
Meier, P.J.	B1.3, Panel	27, 484	Pompei, D.	D1.3	41
Meinel, H.	B1.1	21	Popa, A.E.	D2.7	124
Micheel, L.	A2.1	50	Post, R.E.	B6.6	416
Micheletti, F.	Panel	483	Potter, B.R.	D6.5	453
Mitsui, S.	B3.6	168	Potukuchi, J.	A2.5	64
Miyana, S.	D2.5	119			
Miyauchi, M.	B3.2	156	Quine, J.P.	C5.3	346
Mizobuchi, A.	C2.2	97			
Mok, C.K.	B4.6	251	Raab, A.R.	B4.6	251
Morimoto, T.	D6.4, B4.7	254, 450	Rabanus, G.	A2.1, Panel	50, 483
Motoya, K.	B3.3	159	Ratliff, D.	B2.2	76
Murphy, R.H.	C6.4	430	Raue, J.E.	C2.4	103
			Rauscher, C.	A3.2	132
Nagai, N.	B5.3	326	Rector, R.M.	A3.6	145
Nagao, H.	D5.2	366	Reeves, J.M.	C6.3	427
Ng, E.	A6.1	386	Ren, C.L.	A4.7	227
Nahman, N.S.	C4.3	267	Rhodes, J.D.	A4.2	211
Naito, Y.	D3.6	201	Riad, S.M.	C4.3	267
Nakaji, E.M.	D5.3	369	Riblet, G.P.	B5.2	323
Nakamura, G.	D5.7	380	Risbud, A.A.	D3.8	206
Nielsen, O.	A5.1	300	Rizk, M.R.M.	B2.3	79
Nihei, F.	B3.1	153	Rizzoli, V.	B2.6	88
Nishikawa, T.	A4.8	230	Roberds, J.L.	A4.3	214
Nishizawa, J.	B3.3	159	Ros, A.	D1.3	41
Nogi, S.	C5.7	357	Rubin, D.	A4.1	208
			Ryan, C.	A2.2	54
Ogawa, A.	B4.7	254			
Ogawa, K.	D4.1	276	Saad, A.M.K.	B6.1	405
Ohmori, M.	D5.2, C6.6	366, 435	Safaa-Jazi, A.	D2.3	113
Ohwi, K.	C2.6	108	Saito, Y.	A2.7	67
Okada, F.	C2.6	108	Sakamoto, K.	D4.7	294
Okean, H.	A6.1	386	Saul, D.	A4.1	208
Okuno, Y.	B3.3	159	Schneider, M.V.	A6.4	396
Oliner, A.A.	B6.3	408	Schroeder, W.E.	D4.2	279
Ono, K.	B5.3	326	Schuenemann, K.	A6.2, B6.1	390, 405
Owens, J.M.	D6.1	440	Schuler, D.L.	B4.3	242

INDEX OF AUTHORS

<u>AUTHOR</u>	<u>SESSION</u>	<u>PAGE</u>	<u>AUTHOR</u>	<u>SESSION</u>	<u>PAGE</u>
Schwarzmann, A.	C5.5	352	van de Capelle, A.R.	B6.5	413
Sethares, J.C.	D6.2	443	van der Puije, P.	C4.2	263
Shafai, L.	D3.4	195	vander Sluis, K.L.	C6.2	469
Shigesawa, H.	D2.4	116	Varian, Karl	C5.2	344
Shimamura, T.	A2.4	61	Vendelin, G.D.	A3.6	145
Shimozake, S.	D4.7	294			
Shiue, J.C.	B4.4	245	Wakino, K.	A4.8	230
Shreve, W.R.	D6.5	453	Walker, J.	D5.1	363
Shur, M.S.	A3.8, B4.3, D5.5	150, 242, 375	Walsh, B.	A5.6, D5.8	315, 383
Smith, C.V.	D6.1	440	Wang, J.J.H.	D3.3	192
Snapka, E.P.	D6.1	440	Wang, P.H.	A5.4	309
Solbach, K.	C4.1	260	Washio, M.	A2.4	61
Solodukhov, V.V.	D3.5	198	Wegrowicz, L.A.	D3.7	204
Speciale, R.A.	B2.7, B5.5, C3.4	91, 184, 332	Weisberg, L.	A1.2	17
Stegens, R.E.	A3.1	129	Weller, K.P.	D5.3	369
Stern, R.A.	C2.1	94	Wexler, A.	D3.1	466
Strid, E.W.	A3.3	135	Wight, J.S.	D4.6	291
Sugiura, I.	B3.5	165	Willing, H.A.	A3.2	132
Susman, L.	C3.2	179	Wilson, K.	D5.1	363
Suyematsu, H.T.	D5.8	383	Wolkstein, H.	A3.7	147
Swamy, M.N.S.	A4.5	220	Wu, Y.S.	D5.6	378
Tabuchi, T.	D6.6	472	Yamaguchi, K.	B5.7	338
Tajima, Y.	A5.2	303	Yamamoto, K.	B3.4	162
Takada, T.	C6.6	435	Yanagimoto, K.	B3.1	153
Takashima, I.	B3.2	156	Yee, H.H.	A2.3	58
Takimoto, Y.	A2.4	61	Yip, G.L.	D2.3	113
Takiyama, K.	D2.4	116	Yoder, M.	Panel	483
Takwale, R.G.	D3.8	206	Yokochi, Y.	C2.6	108
Tamama, T.	B3.6	168	Yokouchi, H.	D4.1, Panel	276, 478
Tannenwald, P.E.	C6.4, C6.5	430, 433	Yoshida, S.	A4.9	233
Taub, J.	Panel	484	Yoshimura, K.	B4.7	254
Thal, H.L., Jr.	A4.4	217	Young, F.A.	D1.5	47
Tippett, J.C.	B6.4	411	Young, L.	A1.2, Panel	17, 484
Toda, H.	B3.5	165	Yuan, H.T.	D5.6	378
Tromp, H.	B2.4	82	Yukimoto, Y.	D5.7	380
Tsai, W.C.	D4.4	285			
Tserng, H.Q.	D4.3	282			
Tsudo, M.	B3.6	168			
Tsutsumi, M.	D6.4	450			
Tuan, H.S.	D6.3	447			
Twisleton, J.	D5.1	363			

1978 MTT-S EXHIBITORS

Advanced Absorber Products	Isotronics, Inc.
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